

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|-------|--|---|------------------|---------|------------------|
| L6 | 25 | (silicon same etch\$3) same ((activat\$3 or add\$3 or introduc\$3) same (nitrogen near oxide or "NO.sub.x")) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/24 10:05 |
| L7 | 7 | stadler-maximilian.in. | US-PGPUB; USPAT | OR | OFF | 2005/09/24 10:07 |
| L8 | 12 | schwab-gunter.in. | US-PGPUB; USPAT | OR | OFF | 2005/09/24 10:07 |
| L9 | 1 | schwab-gunter.in. and (nitrogen near oxide or ("NO.sub.x")) | US-PGPUB; USPAT | OR | OFF | 2005/09/24 10:08 |
| L10 | 1 | franke-helmut.in. and (nitrogen near oxide or ("NO.sub.x")) | US-PGPUB; USPAT | OR | OFF | 2005/09/24 10:08 |
| S1 | 23 | (etch\$3 same silicon) same (activat\$3 or treat\$3) same (nitrogen near oxide or "NO.sub.2") | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 09:53 |
| S2 | 1 | ("5843322").PN. | US-PGPUB; USPAT | OR | OFF | 2005/09/21 08:40 |
| S3 | 81194 | (etch\$3 same silicon) same (nitrogen near oxide or nitrous nrear oxide or "NO.sub.x") | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 09:52 |
| S4 | 81194 | (etch\$3 same silicon) same ((nitrogen near oxide) or (nitrous nrear oxide) or ("NO.sub.x")) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 08:47 |
| S5 | 877 | S4 same ((nitric near acid or "HNO.sub.3") same (hydrofluoric near acid or hydrogen near fluoride or "HF")) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 08:59 |
| S6 | 1 | S5 same (activat\$3 same etchant) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 08:59 |
| S7 | 10 | S5 and (activat\$3 same etchant) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/09/21 08:59 |
| S8 | 0 | (etch\$3 same silicon) same (recycly\$3 or recirculiat\$3) | US-PGPUB; USPAT | OR | OFF | 2005/09/21 09:54 |

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|-----|----|--|--------------------|----|-----|------------------|
| S9 | 0 | (etch\$3 same silicon) and (recycl\$3 or recirculat\$3) | US-PGPUB; USPAT | OR | OFF | 2005/09/21 09:55 |
| S10 | 27 | (etch\$3 same silicon) and 216/93. ccls. | US-PGPUB; USPAT | OR | OFF | 2005/09/21 09:55 |